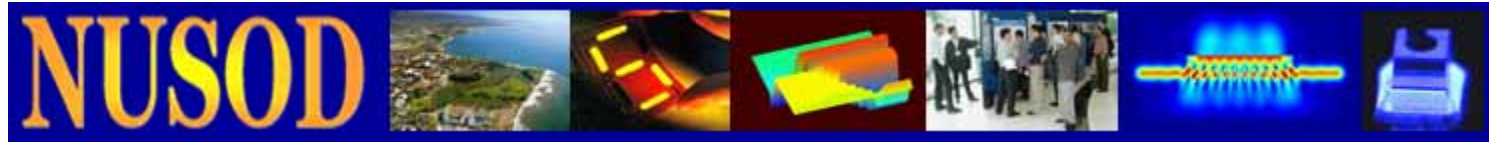


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1 - 5 September 2008, University of Nottingham, United Kingdom



**AlGaIn/GaN based electroabsorption modulator
operating at fiber-optics telecommunication wavelengths**

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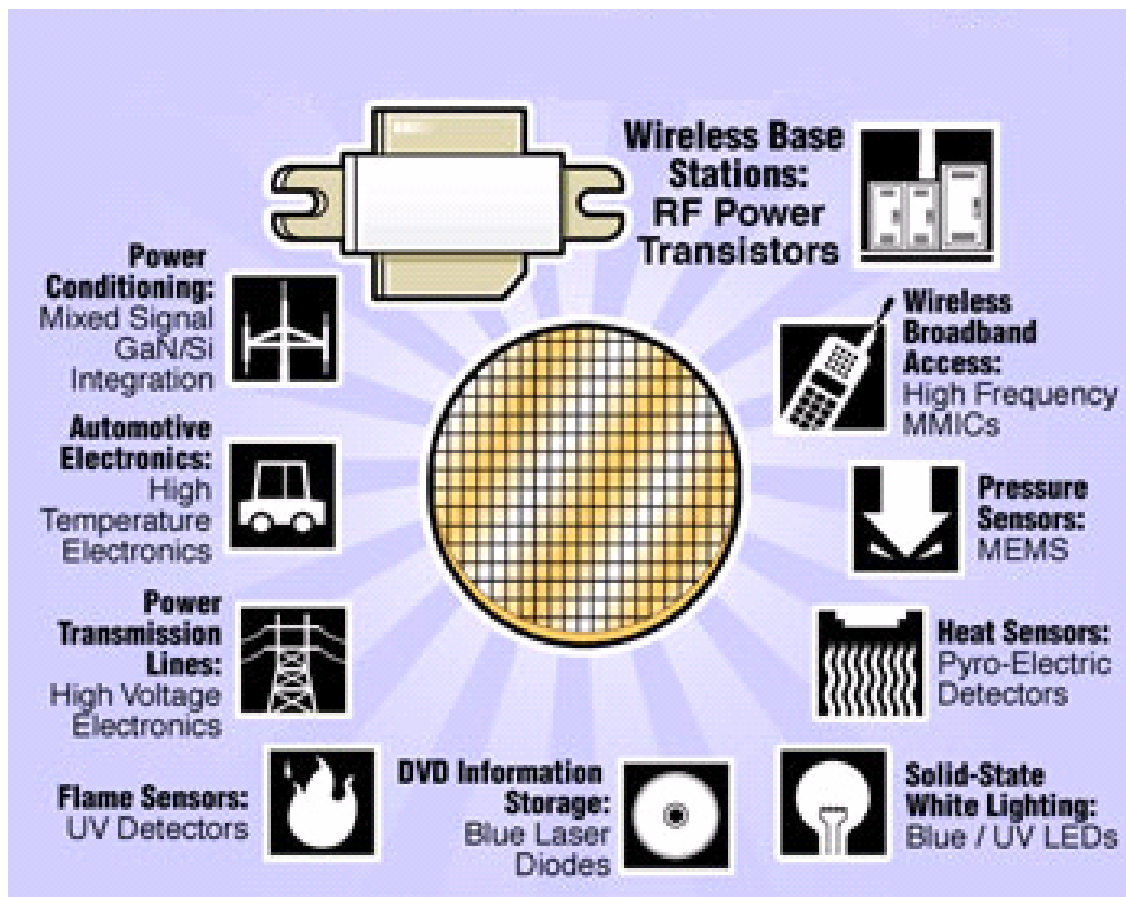
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Outline

- ❖ **INTRODUCTION**
- ❖ **MODELING AND DISCUSSIONS**
 - ✓ **Subband energy and MQW profile**
 - ✓ **The effects of electric field**
- ❖ **Summary**

Applications for AlGaN/GaN



Introduction

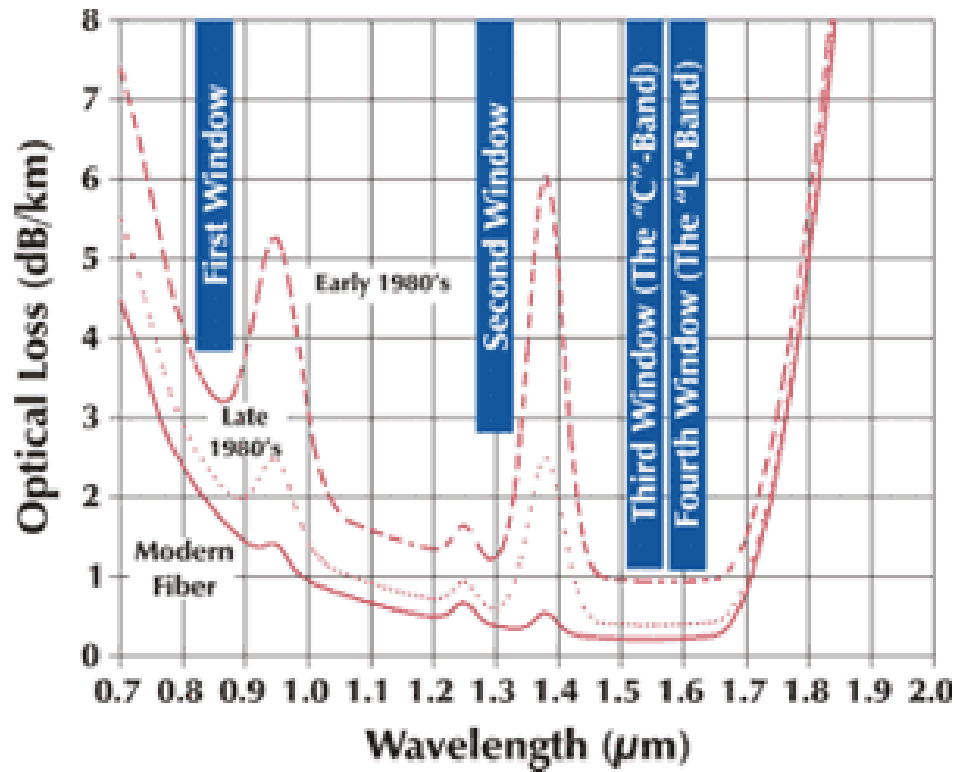
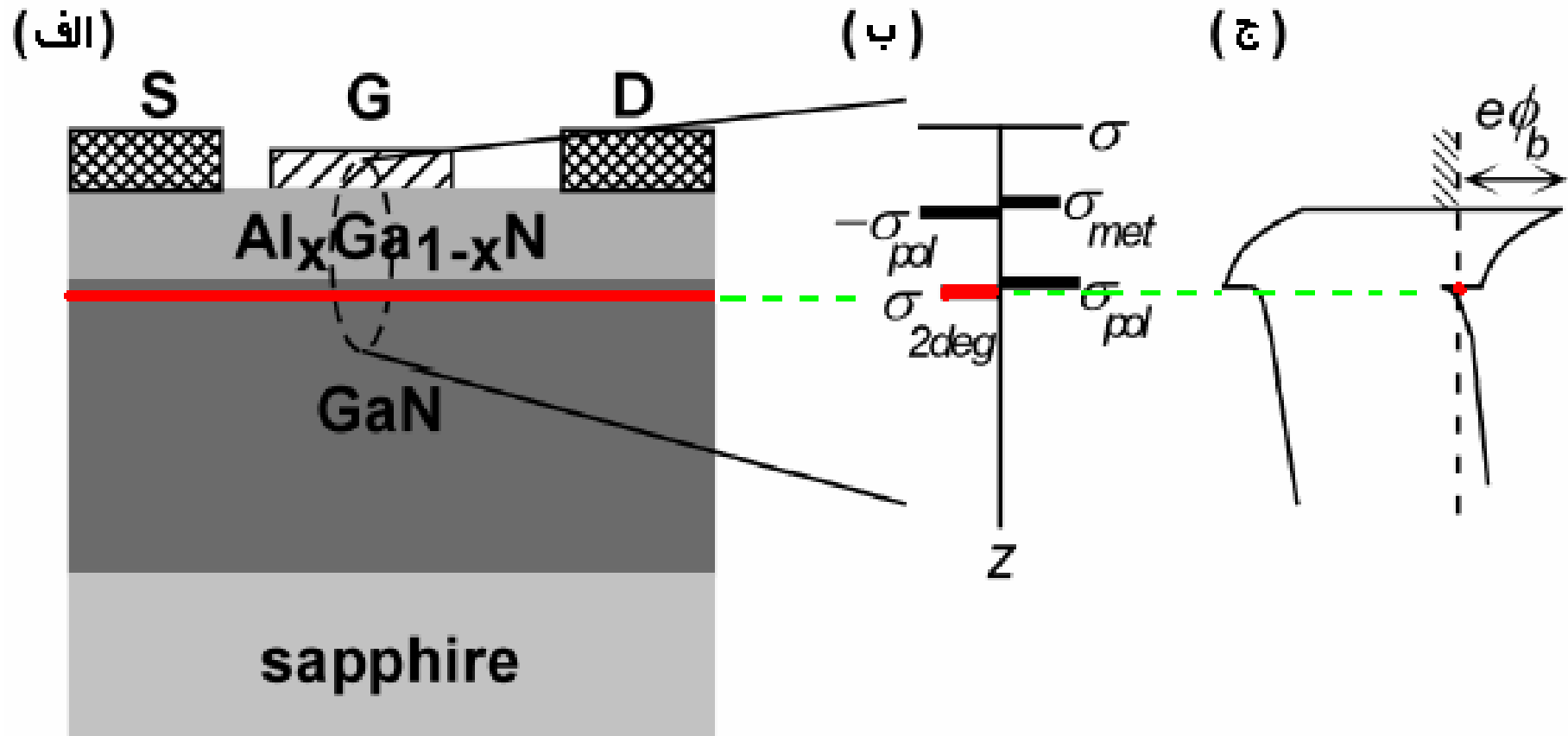


Figure 3 - Four Wavelength Regions of Optical Fiber

Why nitride intersubband devices?

- Wavelength tunability
- Speed:
- High power-handling:
- Excellent optical properties and material hardness
- Added functionalities and improved system performances

2D-Electron density & CB Profile 1



2D-Electron density & CB Profile 2

$$N_s(x) = \frac{+\sigma(x)}{e} - \left(\frac{\epsilon_0 \epsilon(x)}{d e^2} \right) [e\Phi_b(x) + E_F(x) - \Delta E_C(x)]$$

$$N_s = \sum_i ns_i = \sum_i \frac{m^* K_b T}{\pi \hbar^2} \ln \left(1 + \exp \left((E_f - E_i) / K_b T \right) \right)$$

$$\epsilon(x) = -0.5x + 9.5$$

$$e\Phi_b = (1.3x + 0.84) \text{ eV}$$

$$\Delta E_C = 0.7 [E_g(x) - E_g(0)]$$

$$E_g(x) = xE_g(\text{AlN}) + (1-x)E_g(\text{GaN}) - x(1-x) \times 1 \text{ eV}$$

$$= x \times 6.13 \text{ eV} + (1-x) \times 3.42 \text{ eV} - x(1-x) \times 1 \text{ eV}$$

Poisson Eq.

$$\frac{d}{dz} \left[\varepsilon(z) \frac{d\Phi(z)}{dz} \right] = -en(z)$$

$$n(z) = \left(N_d^*(z) - N_a^*(z) - n_{free}(z) + p_{free}(z) - \sum_i ns_i \Psi_i^*(z) \Psi_i(z) \right)$$

$$N_d^* = N_d \left(\frac{1}{1 + 2e^{(E_f - E_d)/K_b T}} \right), \quad N_a^* = N_a \left(\frac{1}{1 + 4e^{(E_a - E_f)/K_b T}} \right)$$

$N_d = 1 \times 10^{17} \text{ cm}^{-3}$
 $N_a = 0$

$$n_{free} = N_C F_{1/2} \left(\frac{E_f - \Phi(z)}{K_b T} \right)$$

$$\left. \frac{d\Phi}{dz} \right|_{z=\text{neutral region in substrat}} = 0, \quad \Phi \Big|_{z=\text{Metal_semiconductor interface}} = \Phi_b,$$

Schrödinger Eq. 1

$$\left[\frac{-\hbar}{2} \frac{d}{dz} \left(\frac{1}{m^*(z)} \frac{d}{dz} \right) + V(z) \right] \Psi_i(z) = E_i \Psi_i(z)$$

$$V(z) = -e\Phi(z) + V_h(z) + V_{xc}(z) + V_{im}(z)$$

$$V_h(z) = [1 - G(z)] \Delta E_c$$

$$G(z) = \begin{cases} (z + z_h)/z_t, & 0 < z < z_h - a_t, \\ \frac{\{z + 3z_h - a_t + (2a_t/\pi) \cos[\pi(z - z_h)/2a_t]\}}{2z_t}, & z_h - a_t < z < z_h + a_t, \\ 1, & z > z_h + a_t, \\ 1 - G(-z), & z < 0, \end{cases}$$

Schrödinger Eq. 2

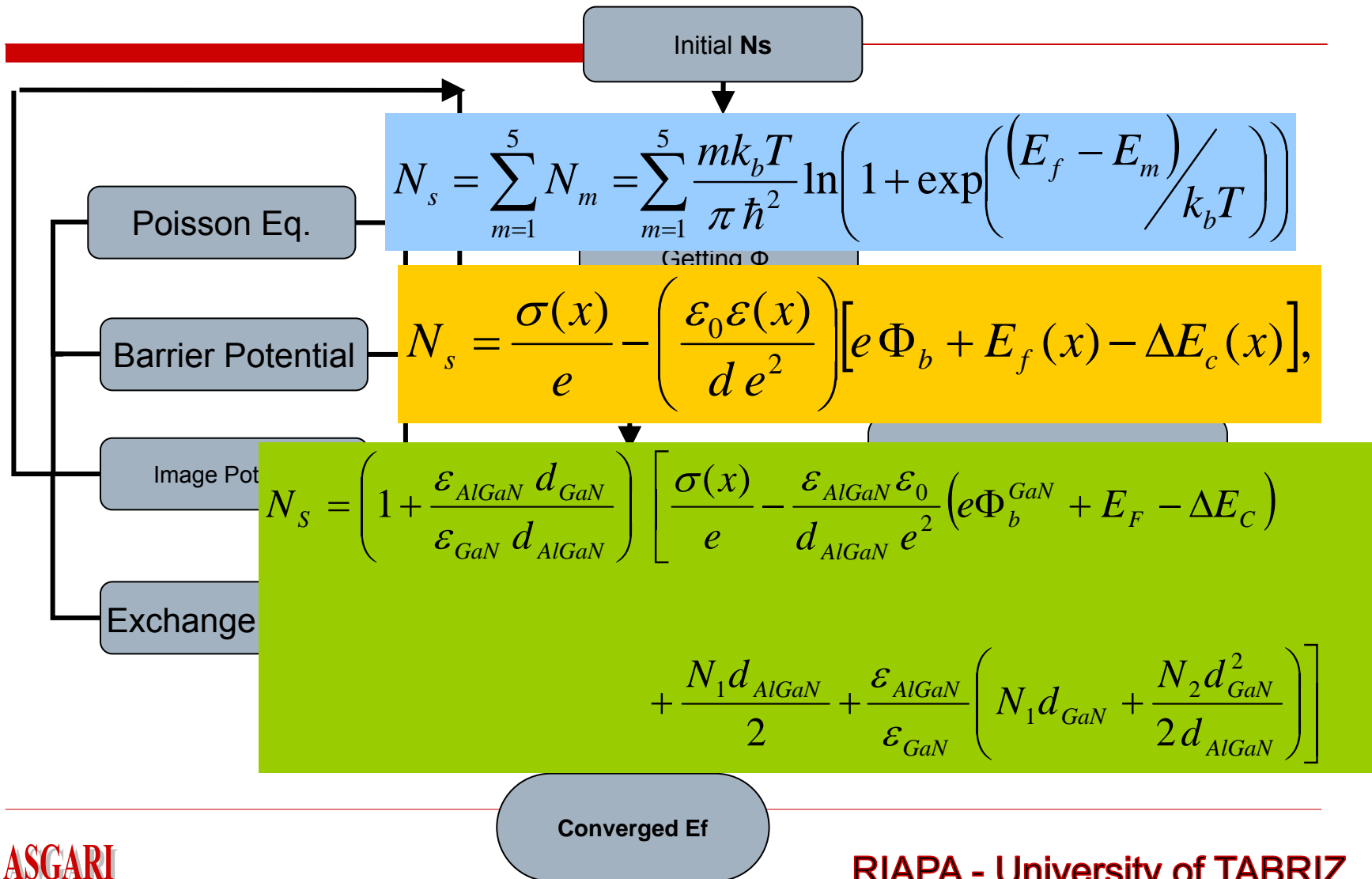
$$V_{xc}(z) \equiv V_{xc}\{n(z)\} \equiv \mu_{xc}[n_0 = n(z)]$$

$$V_{xc}(z) = -\left[1 + 0.773x \times \ln(1 + x^{-1})\right] \times \left(\frac{2}{\pi \alpha r_s}\right) R_y^*$$

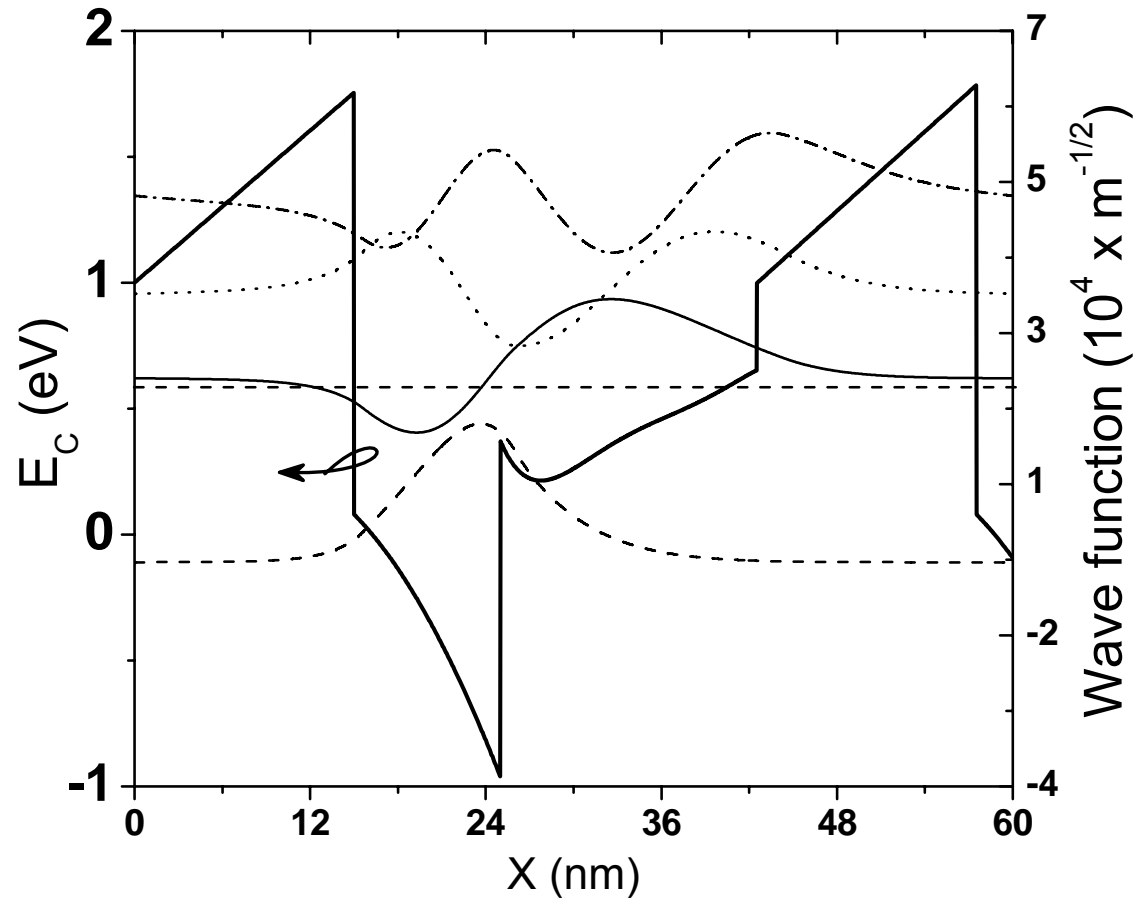
$$\alpha = (4/9\pi)^{1/3}, \quad x \equiv x(z) = r_s / 21, \quad r_s \equiv r_s(z) = \left[\frac{4}{3} \pi a^{*3} n(z)\right]^{-1/3}, \quad a^* = \frac{4\pi \epsilon_0 \epsilon(z) \hbar^2}{m(z) e^2}.$$

$$V_{im}(z) = \begin{cases} \frac{[(\epsilon_{GaN} - \epsilon_{AlGaN})e^2]}{[16\pi\epsilon_0 \epsilon_{GaN} (\epsilon_{GaN} + \epsilon_{AlGaN})z]}, & z > \text{interface} \\ \frac{[(\epsilon_{GaN} - \epsilon_{AlGaN})e^2]}{[16\pi\epsilon_0 \epsilon_{AlGaN} (\epsilon_{GaN} + \epsilon_{AlGaN})z]}, & z < \text{interface} \end{cases}$$

2D-Electron density & CB Profile 3



2D-Electron density & CB Profile 3



Absorption Coefficient

$$\alpha(\omega) = c_{\text{int}} \cos^2(\theta) \left| \left\langle F_n \left| \frac{\partial}{\partial z} \right| F_m \right\rangle \right|^2 \left(\frac{\pi \hbar^2}{m_e k_B T} \right) (N_{sm} - N_{sn}) \times \left(\frac{\Gamma}{2\pi} \right) \left[\left(\frac{\Gamma}{2} \right)^2 + (\hbar\omega - \hbar\omega_0)^2 \right]^{-1}$$

$$c_{\text{int}} = \frac{e^2}{k_B T L C \omega \epsilon_0 n_r m_e}$$

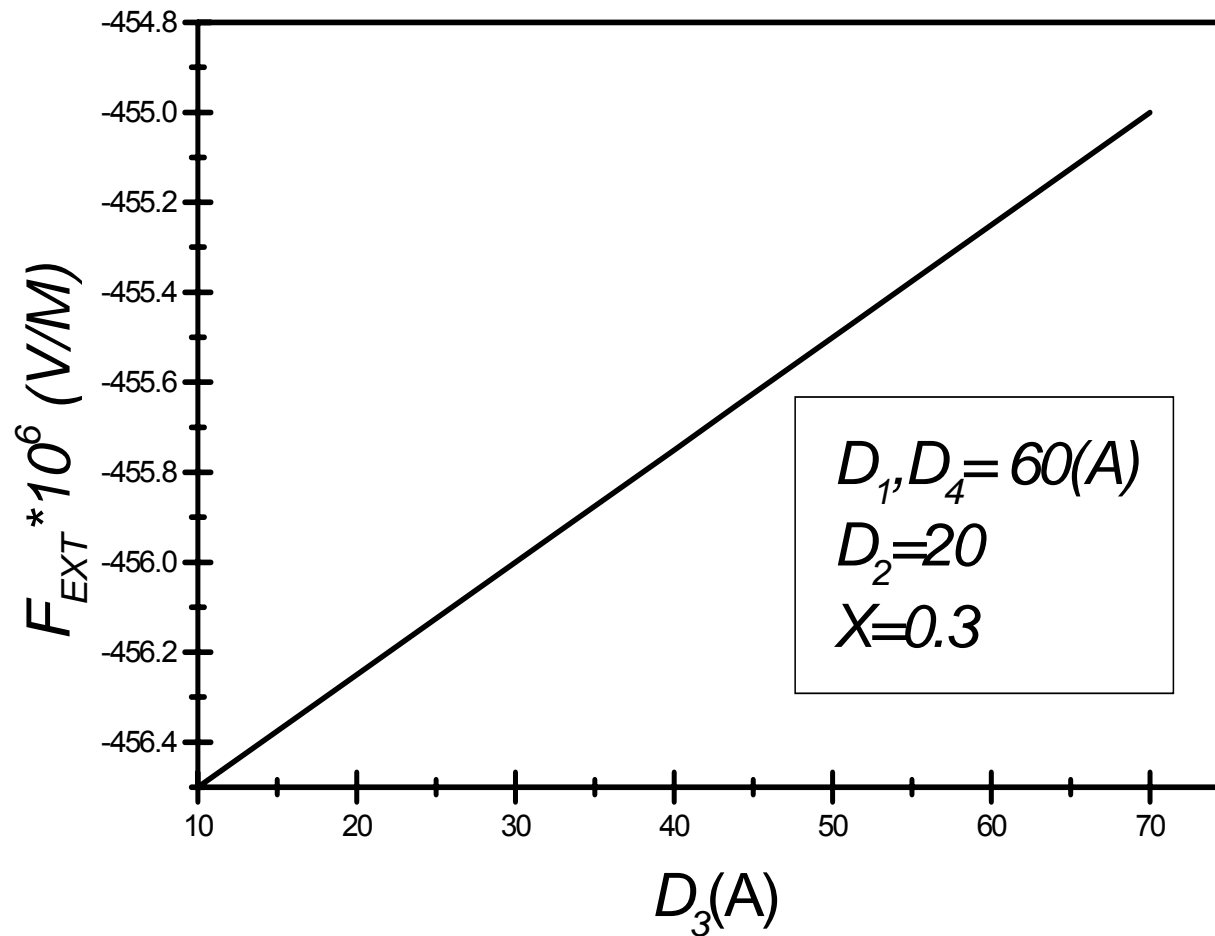
$$\omega_0 = \frac{E_{cn} - E_{cm}}{\hbar}$$

2D-Electron density & CB Profile 3

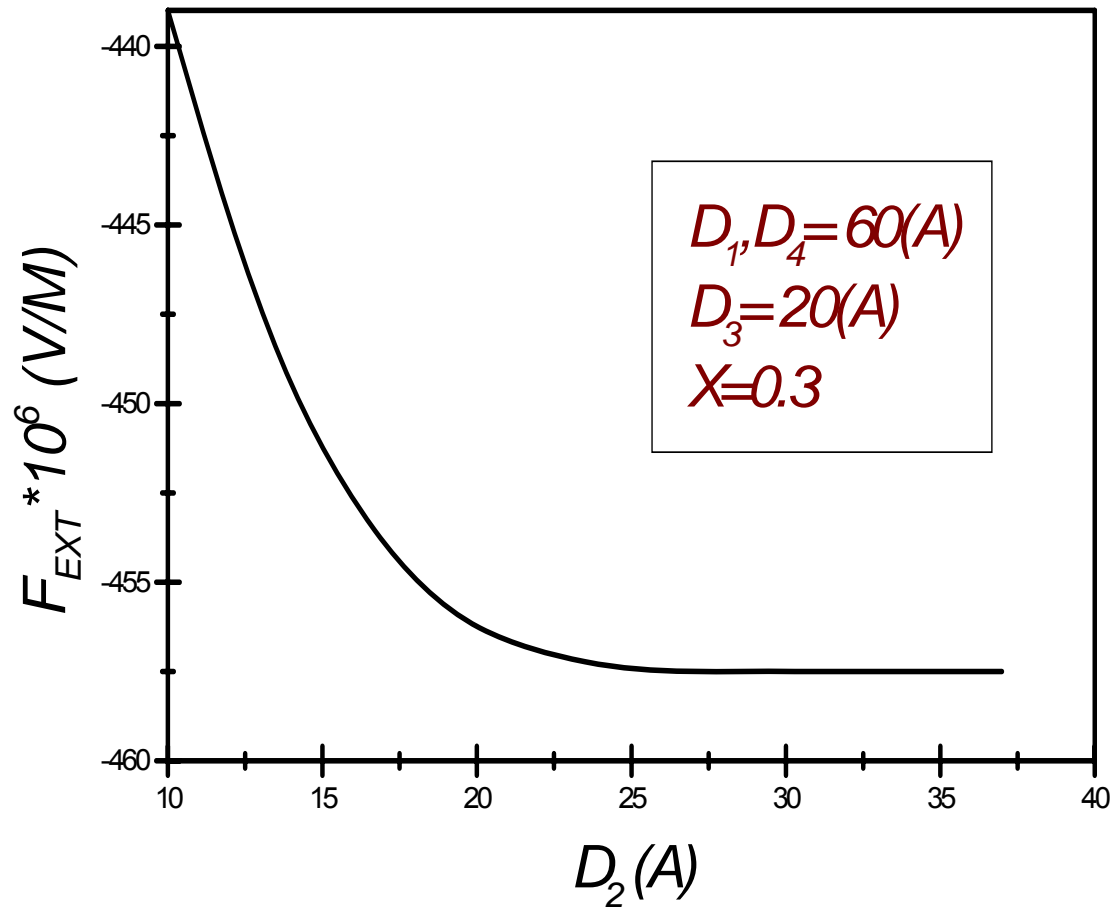
D_1	D_2	D_3	D_4
AlN	GaN	AlGaN	AlN



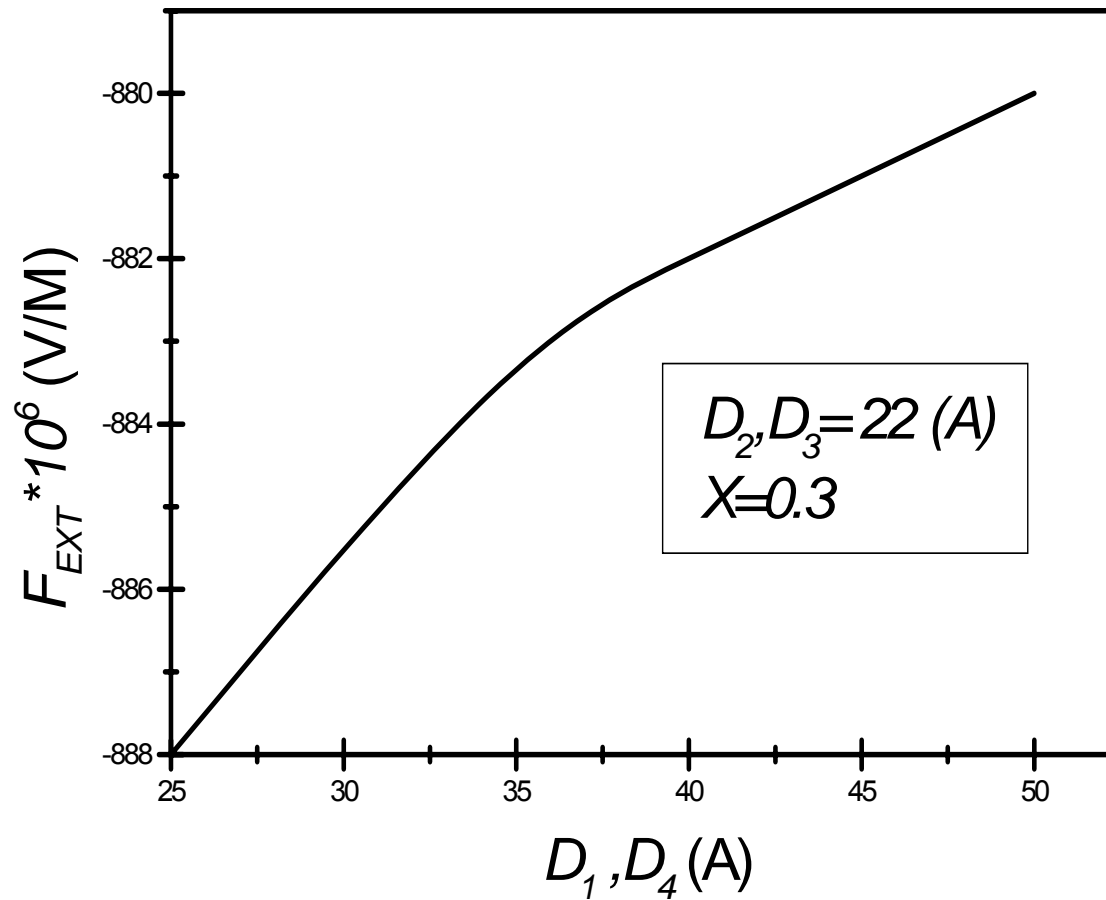
The electric field vs. D3



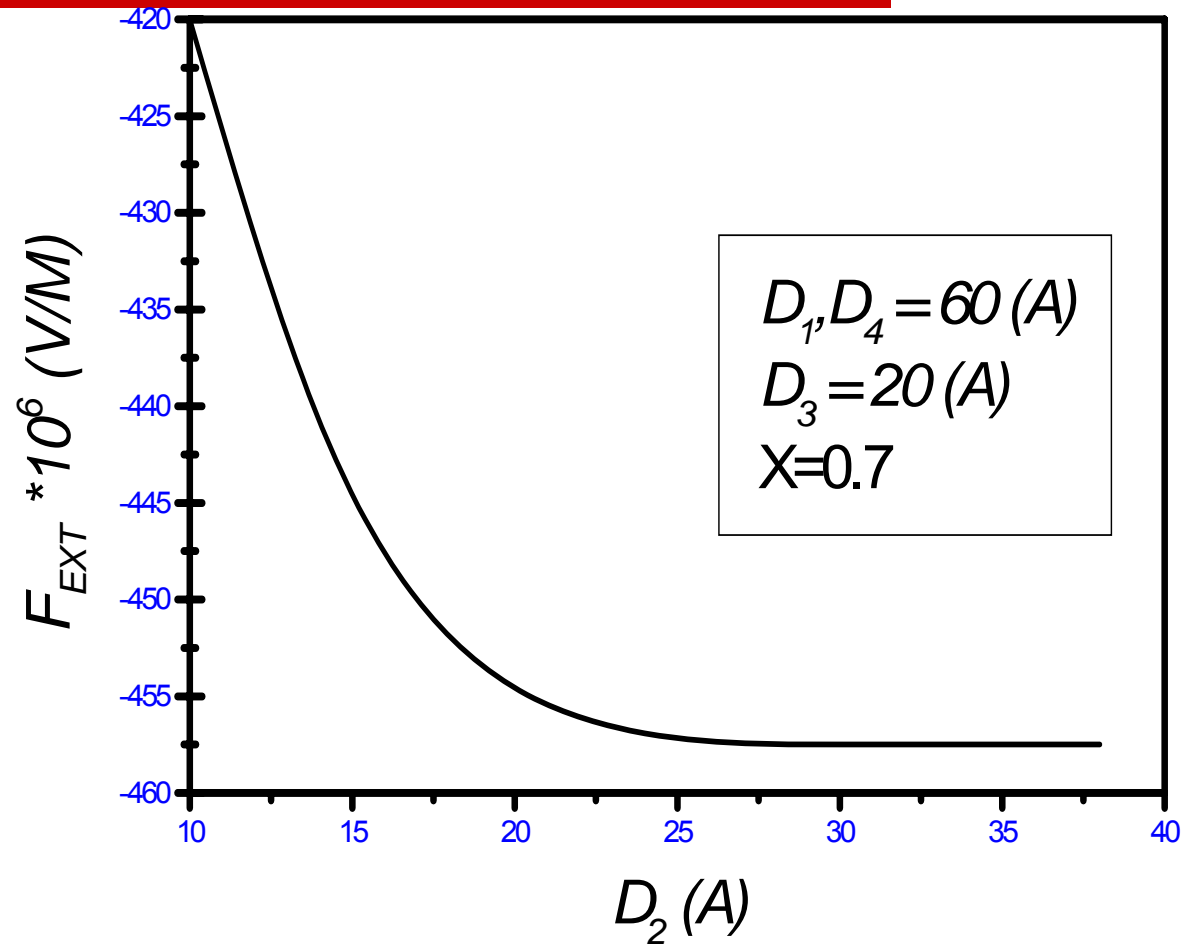
The electric field vs. D2



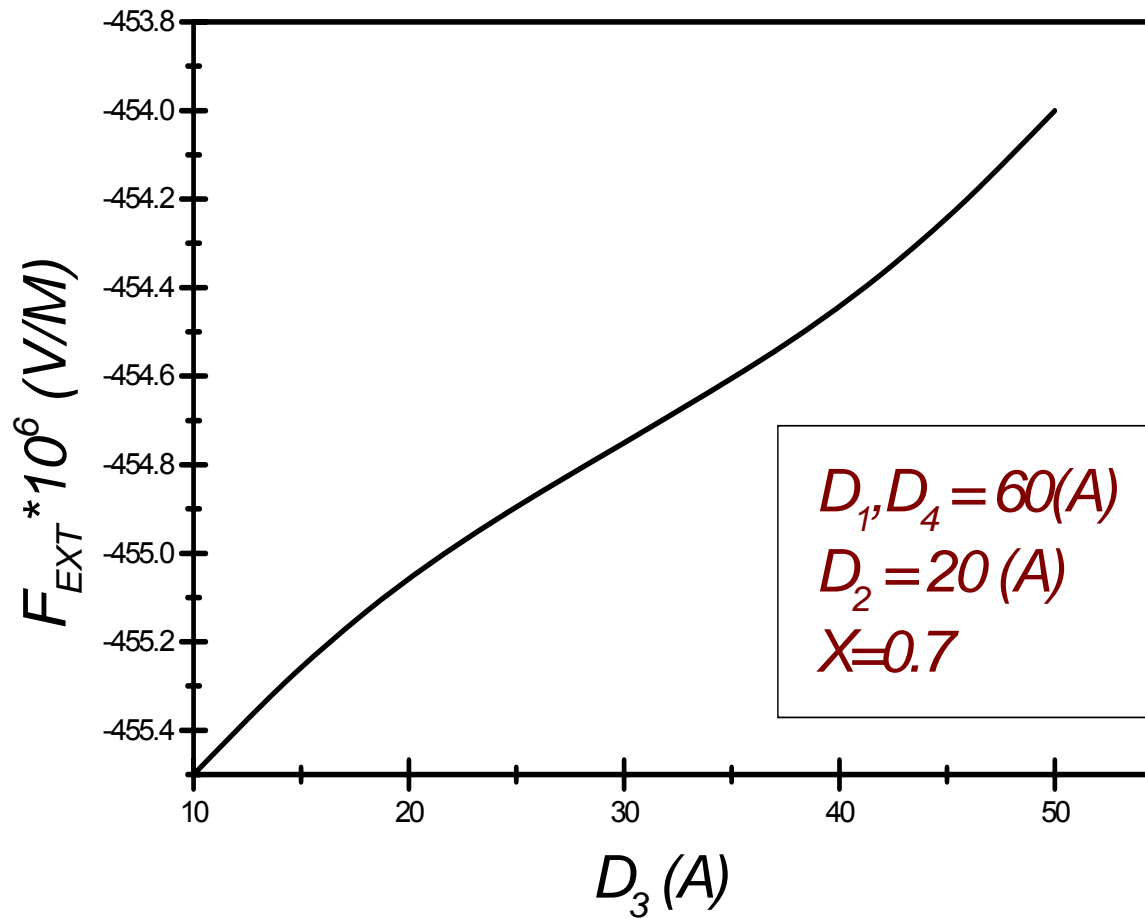
The electric field vs. D1&D4



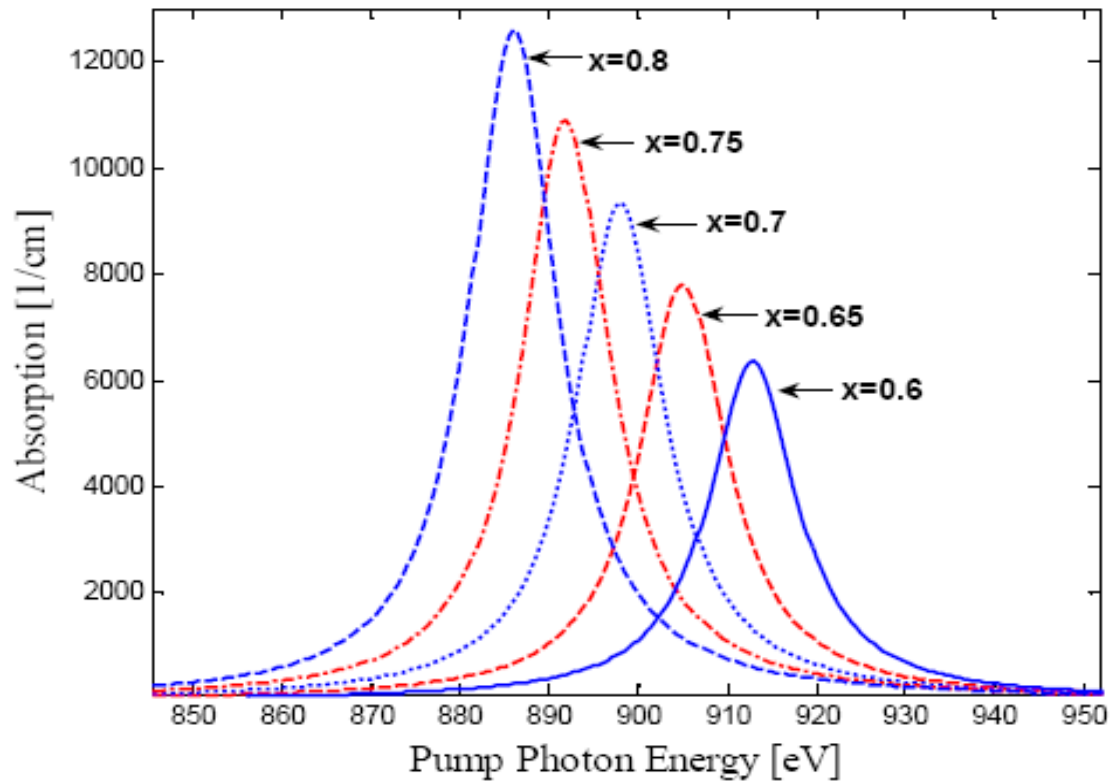
The electric field vs. D2



The electric field vs. D3



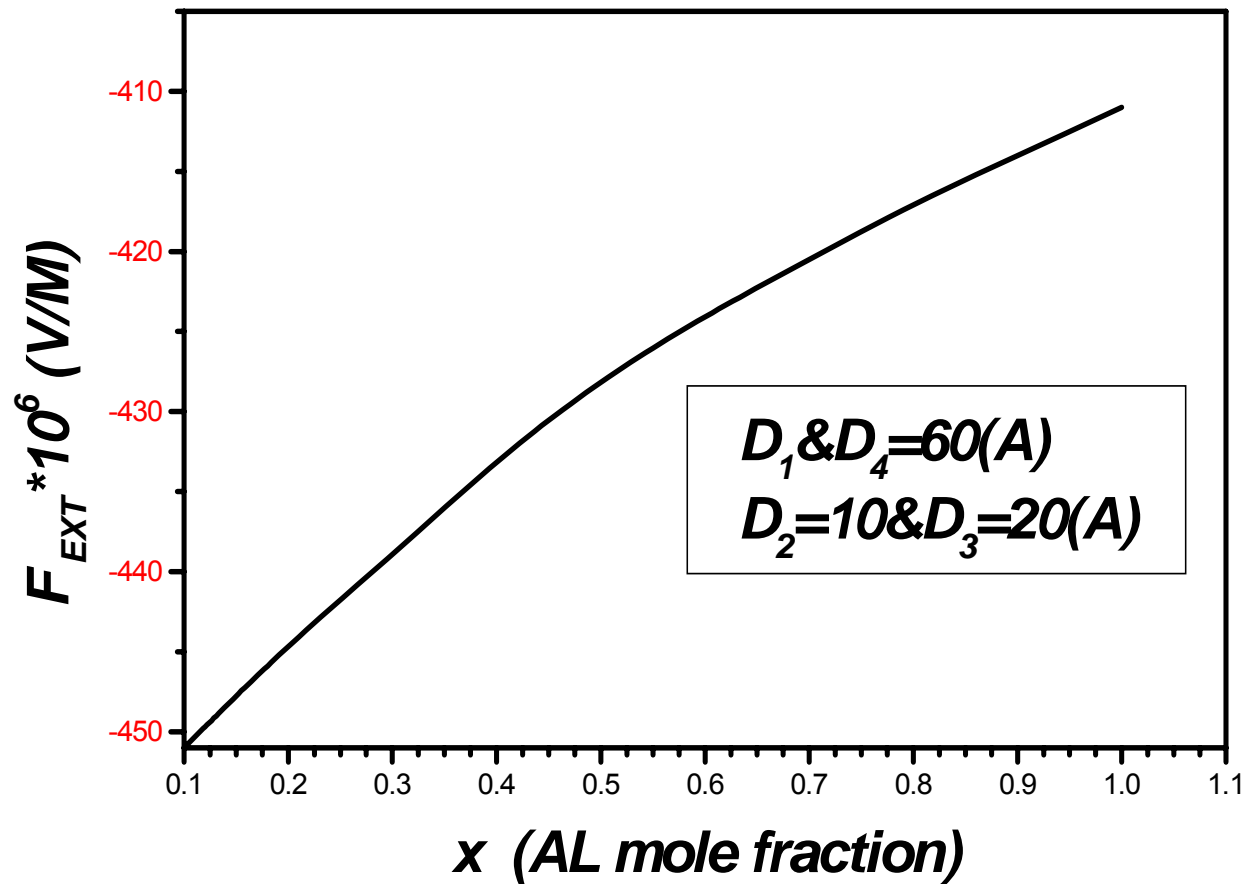
Absorption Coefficient



The electric field vs. Al molar

X	0.1	0.2	0.3	0.4	0.5	0.6	0.6	0.8	0.9
$F \times 10^6$	-644	-630	-621	-615	-610	-595	-583	-577	-569

The electric field vs. x



Summary

Fext ↓ **D3** ↑

Fext ↑ **D2** ↑

Fext ↓ **D1** & **D4** ↑

Fext ↓ **x** ↑

Thanks for Your Attention



Any Question?

